



Atoms of Representation in Natural Language Processing

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Message from the Guest Editor

Dear Colleagues,

As language models take center stage not only in NLP but in a vast array of scientific applications, the question of how it is best to map natural language in textual form into vector space gains more and more interest. While most popular models still use subword tokens as their atomic units, “token-free” methods including character-level, byte-level, and encoding of visual text rendering have been making promising progress. Still, development and analysis of tokenization and untokenization methods is advancing at a slower rate than research in model architecture and optimization technologies, mostly due to the early stage at which representation is applied, which makes evaluation of new algorithms and techniques particularly challenging. Fundamental insights into the effect of representation atomicity on morphological modeling, on multilingual and crosslingual applications, on computation efficiency, on representations of groups in society, and on other aspects, are still being gained, making this research topic ripe for aggregation and integration of findings and methodologies.





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Message from the Editor-in-Chief

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